

Design of High Power S-Band GaN MMIC Power Amplifiers for WiMAX Applications

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Abstract

This paper reports two different S band GaN MMIC PA designs for WiMAX applications. First PA has a 42.6 dBm output power with a 55%PAE @ 3.5 GHz and 16 dB small signal gain in the 3.2-3.8 GHz frequency range. When two of these MMICs were combined by using off-chip Lange Couplers, 45.3 dBm output power with a 45%PAE @3.5Ghz and 16 dB small signal gain were obtained with less than 0.2 dB gain ripple in the 3.3-3.8 GHz frequency range.

1.Introduction

As the market for wireless communication systems such as cellular, personal communications services, and worldwide interoperability for microwave access (WiMAX) coming closer to reality, radio frequency (RF) and microwave power amplifiers have attracted great attention [1-2]. The rapid development of the RF power electronics requires the introduction of wide bandgap material due to its potential in high output power density, high operation voltage and high input impedance [3]. A variety of power amplifier technologies are competing for market share, such as Si lateral-diffused metal-oxide-semiconductors (LDMOS) and bipolar transistors, GaAs metal-semiconductor field-effect transistors (MESFETs), GaAs (or GaAs/InGaP) heterojunction bipolar transistors, SiC MESFETs, and GaN high-electron mobility transistors (HEMTs) [4]. Compared to other compound III-V semiconductor materials, gallium nitride (GaN) provides some superior material characteristics including wide bandgap, high breakdown field, high thermal conductivity, and high saturated velocity [2].

In this work two different GaN based MMIC designs for WiMAX applications will be presented. Agilent Advanced Design System (ADS) is used for design simulations and analyzes. MMICs were designed by using Cree GaN HEMT design kit named Cree_GaN_Design_Kit_v1.101a. Typical HEMT RF performances at 3.5 GHz for this design kit are:

- 4.5 W/mm power density
- 14 dB small signal gain
- High output impedance
- Low input capacitance
- 65% PAE
- 28 volt drain operation

Design goals are minimum 30W output power, 15 dB small signal gain with gain ripple lower than 0.5 dB and maximum -12 dB input return loss in the 3.3 - 3.7 Ghz frequency range.

2. 3.5 GHz GaN MMIC Power Amplifier Design

First GaN MMIC is designed with ideal lumped passive elements with 8x500 μm Cree transistor and second MMIC is its equivalent circuit with transmission lines and real passive elements.

Π type resonance circuits used to match the input and output impedance of the 8x500 μm transistor to 50 ohm. Circuit schematic can be seen in Figure 1. This kind of matching circuit gives the opportunity of bandwidth flatness over the desired frequency range.

8x500 μm Cree transistor has a stability factor of $K \leq 0.5$ at 3.5 GHz and below frequencies. Parallel R-C stability circuit is used at gate port of the transistor to achieve $K > 1$ at all frequencies to prevent any possible oscillation. The designed GaN MMIC circuit with ideal lumped elements and R-C stability circuit is shown in Figure 1. Biasing circuit is embedded into the input and output matching circuits which can be seen in Figure 1.

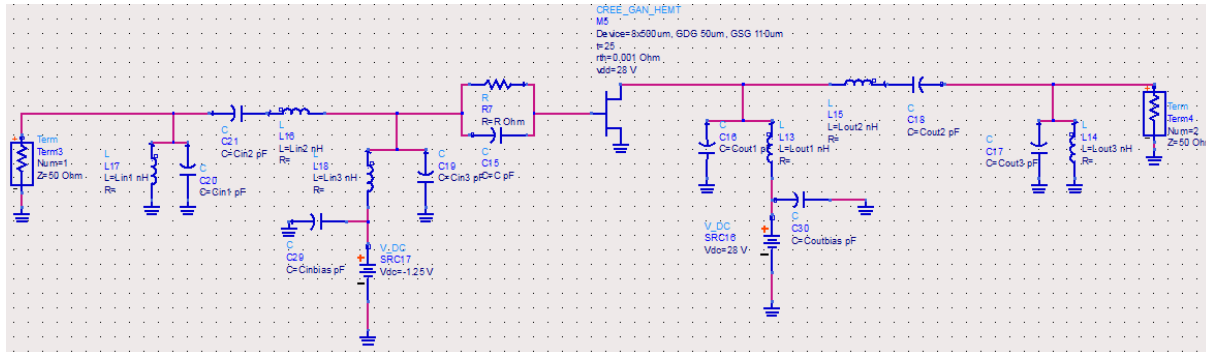


Figure 1: ADS schematic of the designed GaN MMIC Power Amplifier (PA) with ideal lumped elements

S parameter simulation results of the designed GaN MMIC are shown in Figure 2-a. The designed GaN MMIC has lower than -14 dB input return loss at 3.5 GHz and 16 dB small signal gain over the 3 GHz- 4GHz frequency band. It has a stability factor $K > 1$ over 0.5 GHz- 10 GHz frequency band.

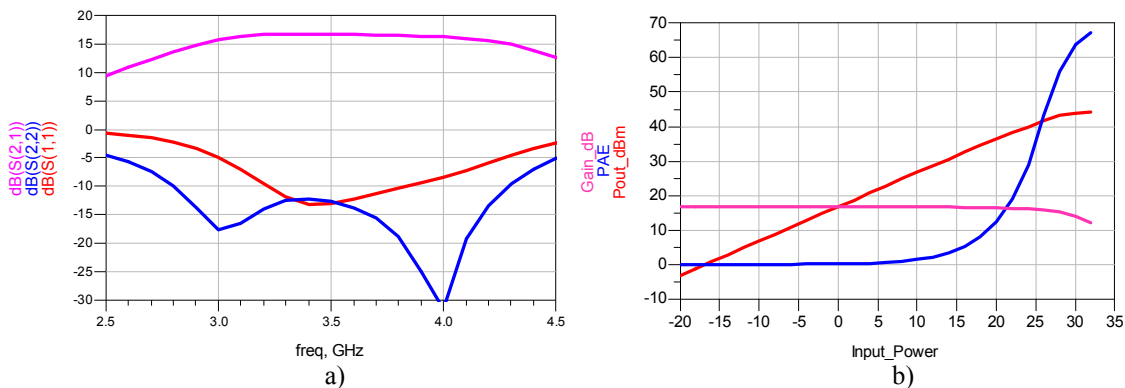


Figure 2: a) S parameter simulation results b) Large signal simulation results, of the designed GaN MMIC PA with ideal lumped elements

Large signal simulation results are shown in Figure 2-b. According to the results GaN MMIC PA has a $P_{1dB} = 42.2$ dBm, $P_{3dB} = 43.9$ dBm and 65% PAE.

After obtaining the design goals with ideal lumped elements, the equivalent circuit with transmission lines and real passive elements is built. ADS layout of that MMIC is shown in Figure 3.

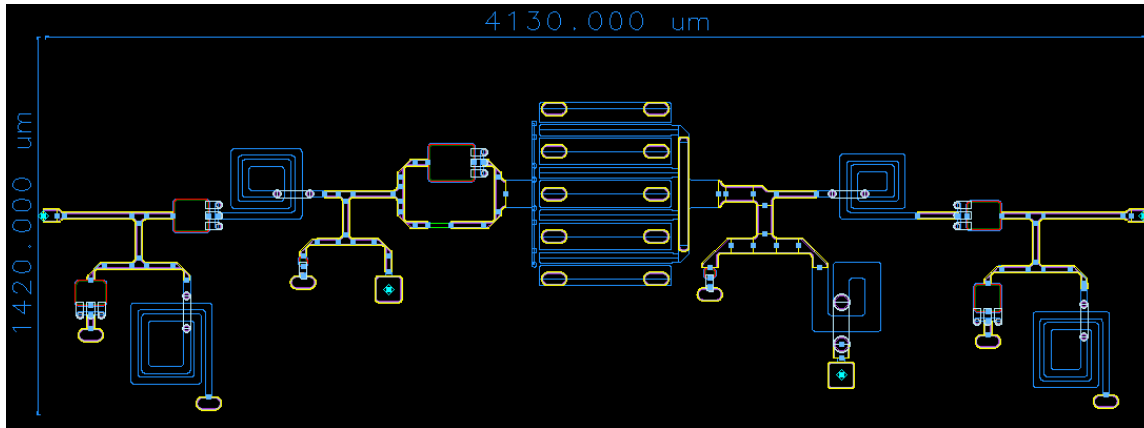


Figure 3: Circuit layout of the designed GaN MMIC PA

S parameter results can be seen in Figure 4-a. The designed GaN MMIC has 16 dB small signal gain over the 3.2 - 3.8 GHz frequency band and -13.5 dB input return loss at 3.5 GHz.

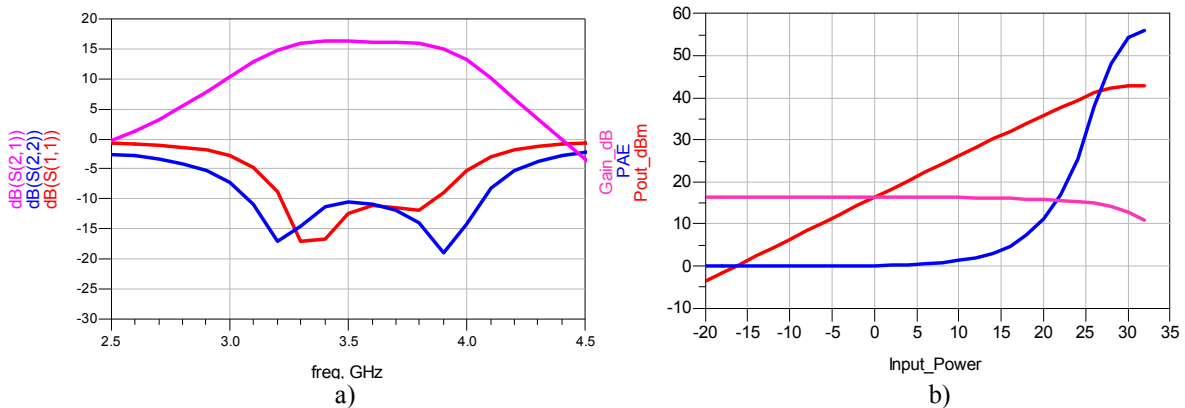


Figure 4: a) S parameter simulation results b) Large signal simulation results, of the designed GaN MMIC PA

The designed GaN MMIC PA is unconditionally stable in 0.5 GHz- 10 GHz frequency range. According to large signal simulation results as seen in Figure 4-b, the designed GaN MMIC has P1dB=41.6 dBm, P3dB=42.6 dBm and 55%PAE.

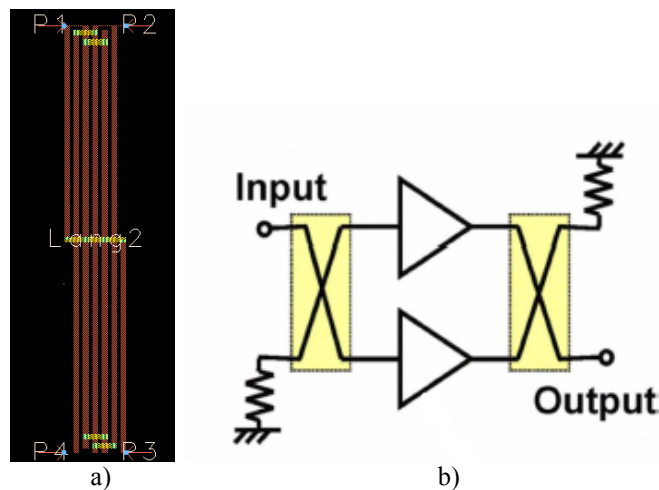


Figure 5: a) Lange Coupler designed with Teflon PCB parameters @3.5 GHz b) Block diagram of the designed GaN MMIC PA

We then combined two of the GaN MMICs with monolithic Lange couplers to increase its output power. Firstly, a coupler was designed to achieve the operation from 3.3 to 3.7 GHz with Cree process parameters. According to design results, the designed coupler has a length of 8.9 mm. Due to high cost of valuable Cree GaN wafer, it is not reasonable to manufacture such large area couplers as on-wafer. Therefore, it is decided to design and manufacture the couplers as off-chip. Then, Lange couplers were designed by using Teflon PCB parameters. Layout of Lange coupler which is designed by using Teflon PCB parameters is shown in Figure 5-a. A block diagram of the designed GaN MMIC PA is shown in Figure 5-b.

S parameter simulation results of the complete design can be seen in Figure 6-a. The designed GaN MMIC is unconditionally stable in the 0.5-10 GHz frequency range. The designed GaN MMIC has 16 dB small signal gain over the 3.3-3.8 GHz frequency band and lower than -30 dB input return loss at 3.5 GHz.

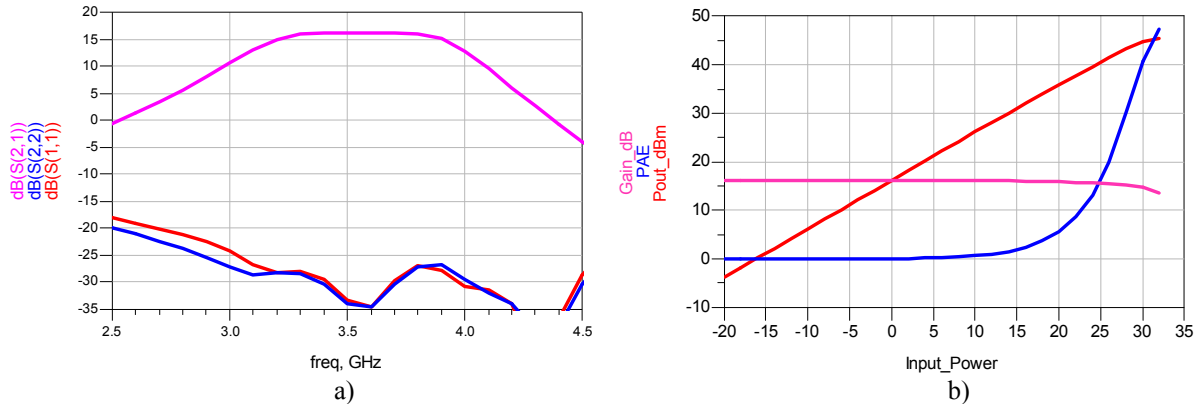


Figure 6: a) S parameter simulation results b) Large signal simulation results, of the complete GaN MMIC PA with Lange couplers

The complete GaN MMIC PA has a $P_{1dB}=44.9\text{dBm}$, $P_{3dB}=45.3\text{ dBm}$ and 45% PAE at 3.5 GHz as seen at Figure 6-b.

3. Conclusion

In this study, two 3.5 GHz high power S-band GaN MMIC PA designs were presented. The first designed GaN MMIC PA shows an output power of 42.6 dBm with 55% PAE @3.5GHz and 16 dB small signal gain in the 3.2-3.8 GHz frequency range. In the second design, two of these GaN MMICs were combined with Lange Couplers in order to increase the output power of the PA. Due to high cost of valuable Cree GaN wafer, Lange couplers were designed and manufactured as off-chip by using Teflon PCB parameters. The second GaN MMIC PA exhibited 45.3 dBm output power with 45% PAE @3.5GHz and 16 dB small signal gain with less than 0.2 dB gain ripple in the 3.3-3.8 GHz frequency range. Designed MMICs will be manufactured by using Shared Multi-Project Set (SMS) Mask Service of Cree GaN foundry. Based on these results, it can be concluded that GaN MMIC technology will take a big share from next generation WiMAX market.

4. References

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